

F I G . 1

Substrate temperature (°C)	20	30	40	50	60	70
Rate of defective spreading of solvent (%)	5	0	0	0	0	0

F I G . 2

Substrate temperature (°C)	20	30	40	50	60	70
Ratio of nozzles (%)	0	0	0	0	0	7

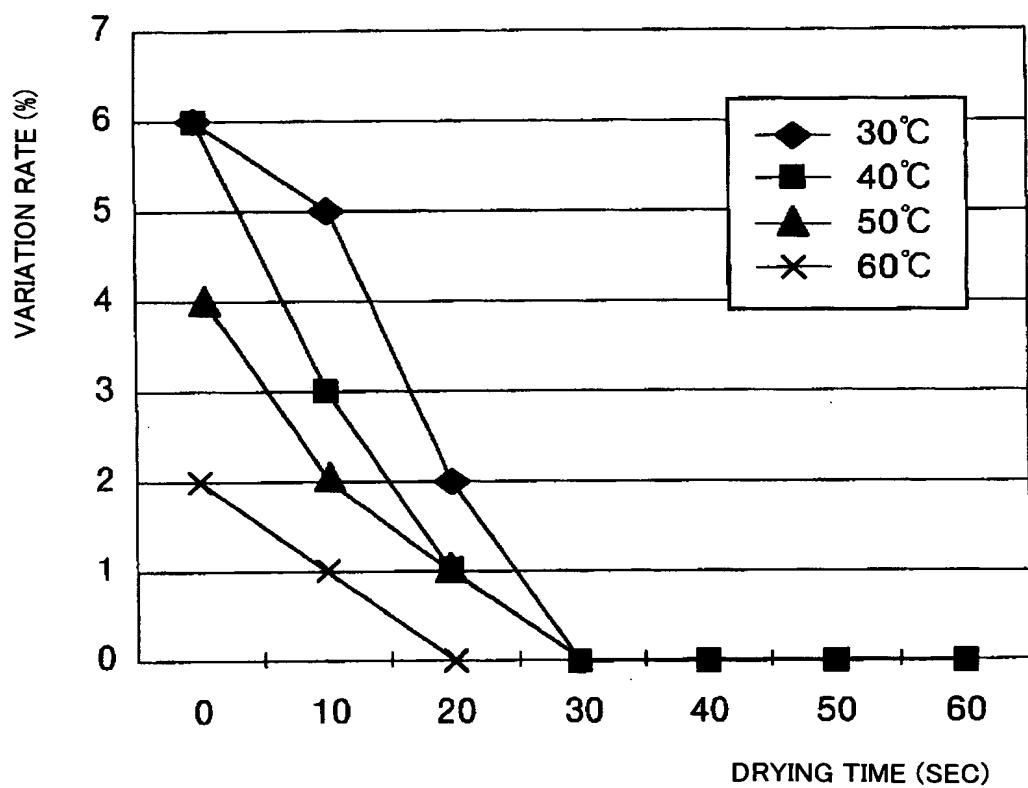
F I G . 3

Substrate temperature (°C)	20	30	40	50	60	70	80
Rate of defective spreading of solvent (%)	5	0	0	0	0	0	0
Rate of defective aggregation of spacer (%)	3	0	0	0	0	2	5

F I G . 4

Substrate temperature (°C)	20	30	40	50	60	70	80
Ratio of nozzles (%)	0	0	0	0	0	12	32

F I G . 5



F I G . 6

